Junction Diode

Lecture - 4

(03/06/2021)

B.Sc (Electronics) TDC PART - I Paper – 1 (Group – B) Unit – 5 by:

Dr. Niraj Kumar

Assistant Professor (Guest Faculty)



Department of Electronics

L. S. College, BRA Bihar University, Muzaffarpur.

Equilibrium Conditions

- ⇒ The Electron and Hole concentrations, under thermal equilibrium can be found by knowing the position of the Fermi Energy E_F with respect to the bottom of the Conduction Band Energy E_C and top of Valence Band Energy E_V . As discussed in pervious Lecture No 24, in case of an Intrinsic Semiconductor, the Fermi Level lies midway between the Conduction and Valence Bands.
- ⇒ With the rise in temperature above 0 K, the Valence Electrons gain thermal energy. A few Electrons in the Valence Band may gain sufficient energy to jump to the Conduction Band.

⇒ Under this condition an empty state or Hole is generated in the Valence Band. In an Intrinsic Semiconductor Electrons and Holes are generated in pairs by thermal energy so that the number of Electrons in the Conduction Band is equal to the number of Holes in the Valence Band.

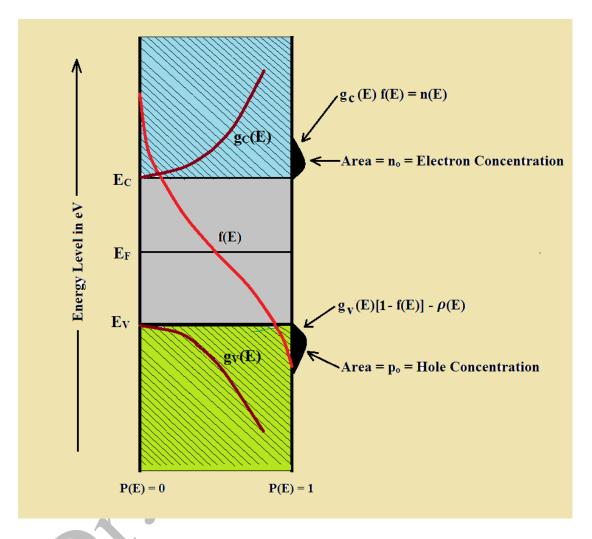


Fig. (1) Shown Density of States Functions Fermi-Dirac Probability Function, and Areas Representing Electron and Hole Concentration for E_F near the Midgap Energy.

⇒ In above Figure (1) shows a plot of the Density of States Function in the Conduction Band gc(E), and the Density of States Function in the Valence Band gv(E), and the Fermi-Dirac Probability Function for T > 0 K when E_F is approximately halfway between E_C and E_V .

Contact Potential

⇒ Upon joining the two regions P and N (shown below in Figure (2)) holes diffuse from P - region to N – region and electrons diffuse from N – region to P – region, as discussed in Previous Lecture – 3.

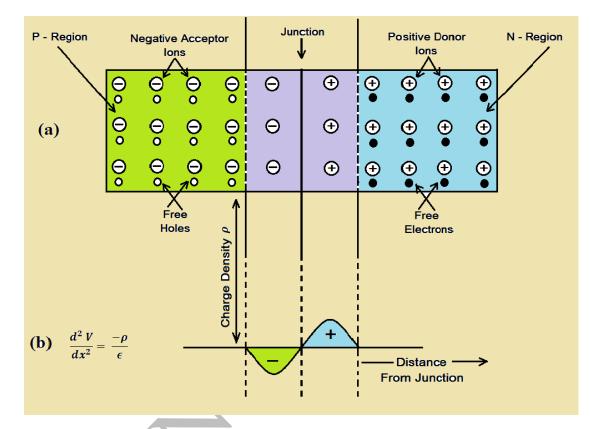


Fig. (2) Shown Joining the Two Regions P and N Holes Diffuse from P - Region to N - Region and Electrons Diffuse from N - Region to P - Region.

⇒ The resulting diffusing current cannot build up indefinitely due to creation of opposite electric field at the junction. The Electric Field E builds up to the point where the net current is zero at equilibrium. The Electric Field appears in some region W (Width) about the junction, called the Transition Region, and there is an Equilibrium Potential Difference V₀ across Junction width W, called a Contact Potential.

- ⇒ The Contact Potential across Junction width W is a build-in Potential Barrier, essential to the maintenance of equilibrium at the junction. The Valence and Conduction Energy Bands, are higher on the P - side of the junction than on the N - side by an amount eV_0 .
- $\Rightarrow \text{ The relations between different quantities under conditions of equilibrium are:-} I_h (drift) + I_h (diffusion) = 0 \qquad (1)$ Ie (drift) + Ie (diffusion) = 0 (2)
- \Rightarrow The relationship between Hole Currents is,

$$I_h(x) = e \left[\mu_h p(x) E(x) - D_h \frac{dp(x)}{dx} \right] \qquad (3)$$

 $\Rightarrow \text{ Which can be simplified as,}$ $\frac{\mu_h}{D_h} E(x) = \frac{1}{p(x)} \frac{dp(x)}{dx} \qquad (4)$

 \Rightarrow where the x-direction is arbitrarily taken from **P** - region to **N** - region.

⇒ The Electric Field can be written in terms of the Gradient in the Potential, $E(x) = \frac{-dV(x)}{dx}$

 $\Rightarrow \text{ Putting the above value of Electric Field } E(x) \text{ into above Equation (4), then that}$ Equation (4) becomes,

 \Rightarrow With the use of **Einstein Relation** for $\frac{\mu_h}{D_h}$, the integration of above **Equation** (5)

provides,

or,
$$\frac{-e}{KT} (V_n - V_P) = logp_n - logp_p$$
(7)

or, $\frac{-e}{KT} (V_n - V_P) = \log \frac{p_n}{p_p}$ (8)

Einstein Relation

The relationship between Diffusion Constant D and Mobility μ is called as Einstein Relation. Diffusion Constant D and Mobility μ is statistical thermodynamic phenomena. Hence they are not independent of each other. It is observed that at fixed temperature, the ratio of Diffusion Constant D to Mobility μ is constant and is known as Einstein Relation. The Diffusion Constants D_h and D_e and Mobilities μ_h and μ_e are related by Einstein Relation given as,

 $\frac{D_h}{\mu_h} = \frac{D_e}{\mu_e} = V_T \qquad (9)$

Hence, D_h = is Diffusion constant for Holes

 D_e = is Diffusion constant for Electrons

 μ_h = is Mobility for Holes

 μ_e = is Mobility for Electrons

 V_T = is volt-equivalent of temperature and is defined as,

$$V_T = \frac{kT}{e} = kT = \frac{T}{11600}$$
Where, **T** = is temperature in Kelvin
k = is Boltzmann constant
(10)

⇒ The Potential Difference $V_n - V_P$ is the Contact Potential V₀. In terms of the Equilibrium Hole Concentrations on either side of the junction, the Contact Potential V₀ may be written as,

$$\therefore V_o = \frac{KT}{e} \log \frac{p_p}{p_n} \qquad (11)$$

⇒ If a <u>Step junction</u> is made up of material with a concentration of N_A accepters/cm³ on the P – side and a concentration of N_D donors/cm³ on the N – side, then above Equation (10) becomes,

$$\frac{p_p}{p_n} = e^{eV_0/KT} \qquad (12)$$

 \Rightarrow Using Law Mass Action the Concentration p_n of Holes in **n** – type semiconductor is written as,

 $p_n n_n = n_i^2 \quad \dots \qquad (13)$

⇒ Using Law Mass Action the Concentration p_p of Holes in p – type semiconductor is written as,

$$p_p n_p = n_i^2 \qquad (14)$$

⇒ Hence Using above Equation (12) and Equation (13) for the Equilibrium condition
 we get the Law Mass Action expression as, ,

⇒ Using Law Mass Action and for the Equilibrium condition

 $p_p n_p = n_i^2 = p_n n_n$, the above Equation (12) becomes,

 $\therefore \frac{p_p}{p_n} = \frac{n_n}{n_p} = e^{eV_o/KT} \qquad (16)$

 \Rightarrow The above relation will be vary useful in determination of I-V Characteristics of the

P-N Junction Diode.

⇒ In the next Lecture - 5, we will discuss the detailed of the Barrier Voltage of
 Contact Potential across the P-N Junction (PART – 1).



to be continued